

10/549609

New PCT National Phase Application
Docket No. 12480-000144/US

IN THE U.S. PATENT AND TRADEMARK OFFICE

Applicant(s): Tomoko AKAI and Danping CHEN
Int'l Application No.: PCT/JP2004/003810
Application No.: **NEW APPLICATION**
Filed: September 20, 2005
For: METHOD FOR PRODUCING HIGH SILICATE GLASS
AND HIGH SILICATE GLASS (as amended)

PRELIMINARY AMENDMENT

Customer Service Window
Randolph Building
401 Dulany Street
Alexandria, VA 22314
Mail Stop PCT

September 20, 2005

Sir:

The following preliminary amendments and remarks are respectfully submitted in connection with the above-identified application. Prior to examination of the present application, please consider the following:

Amendments to the Title begin on page 2 of this Preliminary Amendment.

Amendments to the Claims begin on page 3 of this Preliminary Amendment.